

SBR0220LP-p SBR0240LP-p SBR02M30LP-p SBR02U30LP-p SBR02U100LP-p SBR05U20LP-p

Part Number: **SBR DFN1006-2 Package**
Weight (mg): 0.9202

p = package designator
See Data Sheet

Element	Material Group	Materials	CAS (if applicable)	Average mass homogeneous Material(%)	Percent of whole (%)	Mass (mg)	ppm Homogeneous Material	ppm overall			
Chip	Silicon w/Metal	Doped Silicon*	7440-21-3	100.00%	3.28	0.0302	1000000	32819			
Leadframe	C7025	Cu	7440-50-8	95.90%	38.97	0.3586	959000	373720			
		Si	7440-21-3	0.73%			7250	2825			
		Ni	7440-02-0	3.20%			32000	12470			
		Mg	7439-95-4	0.18%			1750	682			
		Ni	7440-02-0	100.00%			1000000	9020			
Leadframe Plating	Internal plating	Pd	2023568	100.00%	0.09	0.0008	1000000	869			
	middle plating	Au	7440-57-5	100.00%	0.01	0.0001	1000000	109			
	outer plating	Gold	7440-57-5	100.00%	2.55	0.0235	1000000	25538			
Bond Wire	Gold Wire	Gold	7440-57-5	100.00%	2.55	0.0235	1000000	25538			
Encapsulation	EME-G770HT	Silica fused	60676-86-0	93.50%	52.50	0.4831	935000	490870			
		Epoxy resin	-----	3.00%			30000	15750			
		Phenol resin	-----	3.00%			30000	15750			
		Carbon Black	1333-86-4	0.50%			5000	2625			
		Ag	7440-22-4	80.00%			800000	13562			
Die Attach Epoxy	QMI519	palladium compound	----	0.15%	1.70	0.0156	1500	25			
		2,6-Di-tert-butyl-p-cresol	128-37-0	0.01%			50	1			
		Hydroquinone	123-31-9	0.00%			1	0			
		Acrylate	----	15.84%			158449	2686			
		Bismaleimide resin	----	3.00%			30000	509			
		Polymer of polybutadiene and anlydride	----	1.00%			10000	170			
		Total						100.00	0.9202		1000000

Tolerance ±10%

This data is based on information provided by our suppliers. We believe it to be correct but do not routinely validate it by measurement. It is for guidance only and Diodes Inc. does not guarantee its absolute accuracy or completeness

* The Silicon Chip is doped at atomic levels with trace amounts of elements that may include Phosphorus, Boron, Arsenic, and other elements. Metalization may include Titanium, Nickel, Aluminum, Silver or Gold. These substances are not reported where their concentration is less than the minimum reportable level per the guidelines specified in the Tables of EIA JIG-101, [Material Composition Declaration for Electronic Products](#).

This product or product family does not contain any of the following substances except as **CURRENTLY** exempted by ELV II and RoHS and reported above:

- | | |
|--|--|
| Asbestos | Organic tin compounds |
| Antimony Compounds | Ozone Depleting Substances - Class I (CFCs, HBFCs, etc.) |
| Azo compounds | Ozone Depleting Substances - Class II (HCFCs) |
| Cadmium and cadmium compounds | Perfluorooctane Sulphonate (PFOS) or related compounds |
| Certain Shortchain Chlorinated Paraffins | Polybrominated biphenyls (PBB) and Polybrominated diphenyl ethers (PBDE) including DecaBDE |
| Chlorinated organic compounds | Polychlorinated Biphenyls (PCBs) |
| Dimethyl fumarate | Polychlorinated Naphthalenes (> 3 chlorine atoms) |
| Halogens | Radioactive Substances |
| Hexavalent chromium compounds | Red Phosphorus |
| Lead and lead compounds | Tributyl Tin (TBT) and Triphenyl Tin (TPT) |
| Mercury and mercury compounds | Tributyl Tin Oxide (TBTO) |

REACH SVHCs and other Substances of Concern:

- | | |
|---|---|
| Anthracene | 5-tert-butyl-2,4,6-trinitro-m-xylene (musk xylene) |
| 4,4'- Diaminodiphenylmethane | Bis (2-ethyl(hexyl)phthalate) (DEHP) |
| Dibutyl phthalate | Hexabromocyclododecane (HBCDD) |
| Cyclododecane | Alkanes, C10-13, chloro (Short Chain Chlorinated Paraffins) |
| Cobalt dichloride | Bis(tributyltin)oxide |
| Diarsenic pentaoxide | Lead hydrogen arsenate |
| Diarsenic trioxide | Triethyl arsenate |
| Sodium dichromate, dihydrate | Benzyl butyl phthalate |
| Beryllium, Beryllium Alloys and Compounds | Methylene Chloride |
| Hydrazine | Trichloroethene |
| Tetrachloroethylene | Methyl Ethyl Ketone |
| Toluene | Xylenes |
| Toluene Diisocyanate | |